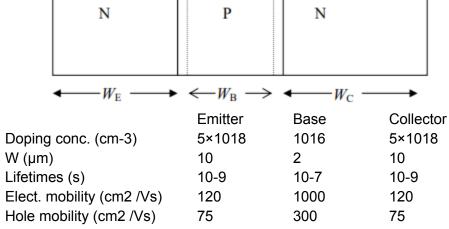
Hayden Fuller Microelectronics HW8

Reading List: Chapter 10, Chapter 11 (pages 389 - 403)

Consider an npn transistor with doping concentration and dimensions shown below. Answer the following questions.

Area A = 1 cm2



A. a. If VBC = 0, and IC = 1 mA, what is value of VBE?

IC=q A DB nB0 / WB \* e^(VBE q/kT)

DB=mu nB  $kT/q = 25.9 \text{ cm}^2/s$ 

nB0=10^20 / 10^16 = 10^4 cm^-3

VBE=0.398

B. b. With the transistor biased as in (a), what is the component of the base current due to recombination in the base region?

 $IBR=q A WB / 2 TB * nB0 e^{(VBE q/kT)} = 7.54x10^{-6} A$ 

C. c. With the transistor biased as in (a), what is the component of the base current due to injection of holes into the emitter region?

IBE=q A DE / LE \* pE0 e^(VBE q/kT) DE=75 \* .0259 = 1.94 cm^2/s pE0=10^20/(5x10^18)=20cm^-3 LE=1.94 10^-9=4.4x10^-5 IBE=0.664uA

D. d. What is the value of the emitter injection efficiency,  $\gamma$ ? IEN=IC+IBR=10^-3 + 7.54x10^-6 IEP=IBE=0.664x10^-6 gamma=IEN/(IEN+IEP)=0.9993

- E. e. What is the value of the base transport factor,  $\alpha T$ ? alphaT=IC/(IC+IBR)=10^-3/(10^-3+7.54x10^-6)0.9925
- F. f. What is the value of the common emitter current gain,  $\beta$ dc? beta\_dc=IC/IB=10^-3/(7.54x10^-6+0.664x10^-6)=121

G. g. If VBE is held constant at the value found in (a), and the collector-to-base voltage is increased so as to reduce the width of the neutral base region, WB, to 10-4 cm, what is the common emitter current gain, βdc now? Note that this is called "base width modulation" (also called "Early effect") which is common in narrow base-width transistors.

IBR=q A WB / 2 TB \* nB0 e^(VBE q/kT) =  $.5 * 7.54x10^{-6}$  A =  $3.77x10^{-6}$  A IC up to 2mA beta\_dc=2x10^-3/(0.664\*10^-6+3.77x10^-6)=451